

Patent Application No. 10/668,702

Customer Number: 42717

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:

Keng-Chu Lin, et al.

Docket No.:

24061.22

(TSMC2002-0893)

Serial No.:

10/668,702

999999

Examiner:

S. A. Gebremariam

Filing Date:

September 23, 2003

Art Unit:

2811

For:

A Method for Improving Time

Dependent Dielectric Breakdown

Lifetimes

Conf. No.:

2195

## RESPONSE TO RESTRICTION REQUIREMENT

Mail Stop: Amendment Commissioner for Patents

PO Box 1450

Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action mailed September 23, 2004, applicant hereby elects, Group I, Claims 1-17, which is drawn to a method of forming integrated circuit device.

Applicant's election is made with traverse on the grounds that the embodiments delineated by the examiner are not patentably distinct and therefore constitute a single invention concept.

An early action on the merits is respectfully requested.

Respectfully submitted,

David M. O'Dell Reg. No. 42,044

Date: 10-20-04

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## **CERTIFICATE OF MAILING**

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Mail Stop: Amendment, Commissioner For Patents, PO Box 1450, Alexandria, VA 22313-1450 on the date below.

Name

Date